Do lomer dislocations spoil high performance of mc-Si solar cells?

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Abstract

Material induced inherent efficiency losses of multicrystalline silicon solar cells have been investigated across all scales from the solar cell down to the atomic structure of the responsible crystallographic defects. Material inherent efficiency losses can be attributed to local increased dark current, which is found at recombination active small angle grain boundaries and accounts to several per-cent absolute. A one-to-one correlation between the density of Lomer dislocations and the strength of the recombination activity of small angle grain boundaries is found by electron-beam induced current measurements and scanning transmission electron microscope investigations. The increased recombination activity of Lomer dislocations is attributed to their immobile nature, which favors contamination by impurities.

1. Introduction

Regarding the current world market solar cells made from crystalline silicon have a share of about 90\%. From these 90\%, 36\% are distributed to Czochalski (CZ, mono-Si) and approximately 54\% to vertical gradient freeze (VGF, multicrystalline (mc)-Si) silicon, respectively [1]. Assuming that the materials have equal doping levels and undergo the same processes, solar cells made from VGF material show lower performance compared to solar cells made from CZ [2]. VGF material, on the other hand has the advantage of lower costs, mainly due to lower energy...
consumption [3]. Nowadays the trend goes strongly towards high efficiency solar cells, e.g. passivated emitter and rear cell (PERC) [4,5], and of course industry endeavors to benefit from the advantage of the moderate costs of mc-Si. The main differences of mono-Si and mc-Si are inherent crystallographic defects in mc-Si (which have been discussed exhaustively in literature, see for instance, [6,7]), and higher contamination of mc-Si by metals, e.g. Fe and Cu, and non-metals, e.g. C and N, see [8,9,10]. Successful efforts have been made to develop VGF materials with a high share of mono-Si [11], so called cast-mono, mono-like or quasi-mono, and VGF materials with controlled growth of certain favorable grain boundaries [12], so called high-performance-multi. However, even in these materials still recombination active defects exists. In solar cells the material inherent efficiency losses are mainly attributed to reduction of the carrier lifetime. At some grain boundaries or material defects the lifetime reduction is very strong and causes, besides of a reduction of the short circuit current density, a measurable increased dark recombination current density, also called diffusion current density, described by its saturation current density $J_0$. This dark current is driven by the grade of contamination of the grain boundaries with impurities as well as the type of contamination. Iron is the most prominent “lifetime killer” in mc-Si solar cells.

The impact on solar cell performance of iron, and iron precipitates, and their respective distribution in VGF grown Si blocks was and is still examined by several authors. Nanometer sized iron silicide precipitates have been reported by Buonassisi et al. [13], and have been determined to be the cause of type-II breakdown sites in mc-Si solar cells [14]. The limitation of solar cell efficiency with respect to the iron concentration has been investigated recently e.g. by Schubert et al. [15]. Mainly the iron stems from the quartz crucible and crucible coating, which is made of silicon nitride [16,17]. The impact of the distribution of iron and iron precipitates during the crystallization on cell performance was investigated exhaustively, and it was revealed that especially the material at the edges of Si blocks are affected by the iron contamination [18]. The material induced inherent efficiency losses reported in the above cited literature is always found to be located at so called “grain boundaries”, “defects”, and “dislocations” of the mc-Si.

Enhanced recombination activity of grain boundaries and other defects in Si was characterized by electron-beam induced current (EBIC) and crystallographic investigations already in the nineteen-eighties. A clear correlation between the EBIC contrast and different dislocation types was made already in 1982 by Pasemann et al. [19], however, the material used in this investigations was CZ grown. Also Kittler et al. showed the recombination activity of dislocations on a model material and found a correlation between EBIC contrast and the contamination level of the dislocations [20]. In mc-Si material it was found that mostly small angle grain boundaries (SAGB) show the strongest EBIC contrast and highest recombination activity [21,22,23]. Seifert and colleagues could reveal in their work a correlation between the density of dislocation and enhanced recombination activity by EBIC measurements [24]. In this work we will try to go further not showing only a one-to-one correlation between dislocations, but revealing the causality between the density of a special type (Lomer) dislocations and local efficiency losses in solar cells made from industrial mc-Si.

2. Experimental

The challenge of the present work is to find exactly the recombination active crystallographic defects having a size of some nm² on a solar cell which is some hundred cm² large. The approach we used is a combination of quantitative dark lock-in thermography (DLIT), scanning- and (scanning) transmission electron microscopy methods (SEM, (S)TEM) and extremely precise, partly in-situ EBIC supported, focused ion beam (FIB) sample preparation. Using these methods in a reasonable manner a one-to-one correlation of the positions of efficiency losses and corresponding crystallographic structures over all scales is possible. For the investigations standard industry screen printed mc-Si solar cells with Al rear contact have been used.

The detection of the position of material induced inherent efficiency losses, i.e. positions with high $J_0$, have been carried out by quantitative DLIT analysis using the Local-IV-2 software [25]. For the local efficiency analyses the global $J_{sc}$ of the cell taken from cell flasher data was used. Identified areas of high $J_0$ have been cut out and EBIC investigations have been carried out for high resolution imaging of the defect structure. Using EBIC images small parts of grain boundaries (GBs) showing different EBIC contrast, i.e. different recombination activity, have been cut out with high spatial precision parallel and perpendicular to the solar cell’s surface by focused ion beam (FIB). The
resulting FIB lamellas have been thinned down to enable high-resolution imaging of the atomic structure with different STEM methods using a probe C₃-corrected FEI-TITAN 80-300 electron microscope.

3. Diffusion current vs. efficiency evaluation and sample selection

3.1 Diffusion current and efficiency in mono-Si and mc-Si solar cells

Figure 1 illustrates the difference between the diffusion current density \( J_{01} \) distribution in mono-Si and mc-Si solar cells. In Fig. 1(a) and (b) electroluminescence (EL) images taken at 600 mV of a mono-Si (a) and a mc-Si (b) solar cell are shown. Both images are normalized to the respective maximum signal and are scaled from 0 to 1 in arbitrary units. The EL image of the mono-Si looks much more homogeneous compared to the mc-Si solar cell. Whereas only some dark features due to series resistance effects at interrupted grid fingers are detectable in the mono-Si cell, dark lines in high density are visible in the mc-Si solar cell. Each of these clusters of dark lines, some are exemplarily marked by the white arrows in (b), contains recombination active grain boundaries. In the mc-Si solar cells good areas (black arrows) showing no dark lines, areas with a moderate density of recombination defects (rectangle), and areas with a high density of recombination active defects (circle) can be found.

Fig. 1. (a) and (b) are EL images of a mono-Si and a mc-Si solar cell, respectively (scaling 0 to 1 in a.u.). Arrows in (a) denote interrupted grid fingers. Arrows, rectangle, and circle in (b) see text. (c) and (d) are the corresponding DLIT-based \( J_{01} \) images (scaling 0 to \( 2 \times 10^{-11} \) A/cm²). (e) and (f) are the corresponding simulated efficiency maps (scaling (e): 15 to 18 %, (f): 14 to 17 %). The color bar below the images holds for all scale values given for each picture separately in the text and caption. Length scale in (a) holds for all pictures.

Using the quantitative local current-voltage curve analysis of [25] the \( J_{01} \) images of these cells have been obtained and are displayed for the mono-Si cell in Fig. 1(c) and for the mc-Si cell in (d). Both images are scaled form 0 to \( 2 \times 10^{-11} \) A/cm², refer to the color scale below the images. At the bus bars a pixel correction is used, which allocates pixel values from the surrounding of the bus bars. This option was used since at the bus bars efficiency losses due the solar cell process are observed (e.g. missing BSF), but here we only want to compare material inherent losses. The mc-Si solar cells shows a very inhomogeneous distribution of \( J_{01} \) clusters (bright in Fig. 1(d)), these cluster correlate one-to-one to the dark cluster of the EL image in (b). In the mono-Si such cluster are not detectable. The maximum local \( J_{01} \) values are about \( 5 \times 10^{-10} \) A/cm² at the mc-Si cell and \( 5 \times 10^{-12} \) A/cm² at the mono-Si cell. The simulated efficiency images of both cells in Fig. 1(e) and (f) clearly show that local losses at the \( J_{01} \)
cluster account for to 4 % (abs.) in this mc-Si solar cell; the scaling is 15 to 18 % for (e), and 14 to 17 % for (f). Please note, that the cell tester data, i.e. the global efficiency, was measured to be 15.6 % for the mc solar cell and 17.3 % for the mono cell, the simulated data account to 15.7 % and 17.3 %, respectively. Note, also that the resistivity of the material (about 1.5 Ом•cm) and series resistance (mono-Si cell: about 0.6 Ом•cm² cell, mc-Si cell: 0.7 Ом•cm²) of both cells are close to each other, hence the local IV simulations are quite well comparable. However, for simplicity the series resistance was assumed to be homogeneous across the cell area each, which is not correct, but leads only to the artifact of slightly increased efficiency values at the interrupted grid fingers in the simulation of the mono-Si cell, see black arrows in Fig. 1(e). Comparing Fig. 1(d) and (f) it becomes obvious that there is a strong correlation between cluster of high $J_{01}$ and low efficiency. Furthermore, the efficiency distribution of the mono-Si cell is much more homogeneous than that of the mc-Si cell.

3.2 Sample selection

Figure 2(a) shows the simulated $J_{01}$ image of another mc-Si solar cell. Several cluster of increased dark current density $J_{01}$ could be detected and the main cluster was cut out and once again imaged by Local-IV-2 method. The obtained $J_{01}$ image of this small sample is shown in Fig. 2(b). The increased $J_{01}$ is structured in lines and small cluster with areas of very low $J_{01}$ in between. To reveal the efficiency losses at these $J_{01}$ clusters a simulated efficiency map of the sample is given in Fig. 2(c). It is obvious that the efficiency is lower exactly at the position of high $J_{01}$, where the efficiency was simulated only to be in the range of 12 to 14 % which is about 3 to 5 % lower than the surrounding areas which show efficiencies of up to 17 %. Note that all these efficiency simulations are made under the assumption of electrically isolated pixels, hence these are efficiency potential values. At the right hand side of Fig. 2 a diagram illustrating the dependence of the efficiency on the diffusion current density at the area marked by the circle in Fig. 2(c) is given. The upper efficiency limit follows the relation $\eta \sim \ln(1/J_{01})$; of course the efficiency is affected also by other effects such as increased series resistance or shunting. Recombination current ($J_{02}$) does not play a role in this area, however the noise of the measurements and subsequent errors in the simulation are present as well and lead to a scatter of the data.

Using EBIC, images of the cut-out sample were taken and stitched afterwards as shown in Fig. 2(d). The resulting overview clearly demonstrates that the low efficiency areas (i.e. high $J_{01}$) correlate to lines of low EBIC contrasts, which is exemplarily shown by the black arrows in Fig. 2(d). Due to the EBIC images, which shows a much higher spatial resolution than the DLIT images, it is possible to determine exactly the grain boundaries, which show enhanced $J_{01}$. To reveal the nature of the grain boundaries forming the grain structure of the sample, an electron backscatter diffraction (EBSD) mapping was done at the same position as the cut out sample on the direct adjacent wafer of the solar cell. The distance between the two wafers is approximately 100 μm, hence we can
assume a very similar grain structure in both samples. The typical inverse pole figure representation of the surface grain orientations is given in Fig. 2(e). The black lines are coincidence site lattice (CSL) grain boundaries, which border the obvious grains with distinct different orientation. The red lines are small angle grain boundaries. By comparing Fig. (d) and (e) it becomes clear that all recombination active structure detected by DLIT and EBIC correspond directly only to small angle grain boundaries (SAGB). The CSL GBs do not show any recombination activity in Fig. 2(d) (see [21,22,23] for comparison). Some of the SAGB are marked by the black arrows and the circle in Fig. 2(e). At the position of the circle a detailed EBIC image was taken, which is given in Fig. 3(a). In Fig. 3(a) some recombination active GBs are visible. It is obvious that the EBIC contrast is different at some GBs and even at one and the same grain boundary the EBIC contrast changes from strong to weak. Four positions with different strong EBIC contrast have been chosen, which are marked in Fig. 3(a), the EBIC contrast decreases from position 1 throughout position 4. Please note that positions 1 and 3, as well as 2 and 4 belong to the same GB, respectively. Exactly at these positions planar, i.e. parallel to the surface, FIB samples have been prepared for subsequent STEM investigation.

4. Electron microscopy investigations of the recombination active structure

To reveal the crystallographic structure of the recombination active grain boundaries, they have been further investigated by high resolution EBIC and STEM. In Fig. 3(b) a superposition of a high magnified EBIC image (in the background) of position 2 and stitched low-angle annular dark field STEM images (LAADF) is shown. At this high magnification the EBIC contrast turns out to be more or less point like, with each point having a different strength.

Fig. 3 (a) high resolution EBIC image of the area marked by the circle in Fig. 2(d). (b) Superposition of stitched LAADF images of the small angle grain boundary and a higher magnified EBIC image of position 2. The inset shows a SAED pattern revealing that the grain boundary is a small angle grain boundary. (c) and (d) LAADF-STEM images of position 2 and 4 from (a), respectively.

By comparing the LAADF images, which are located at the correct lateral position in relation to the EBIC image, and the positions of the EBIC events, a clear correlation between the EBIC events and the grain boundary is observed. The red circles at the LAADF images of the GB mark the EBIC events, and their diameter correspond to
the respective strength of the EBIC signal. By selected-area electron diffraction (SAED) the grain boundary was
determined to be a small angle grain boundary (SAGB) with a tilt angle of about 3.4° around the <110> direction
pointing out of the pattern plane. As demonstrated for that example, also all other investigated grain boundaries with
high recombination activity are SAGBs. In Fig. 3(c) and (d) higher magnified LAADF-STEM images of position 2
(c) and of position 4 (d) are shown. At the small angle grain boundaries bright contrasts points are found which are
associated with strain fields of partial dislocations and perfect boundary dislocations. It was also found that twin
boundaries (Σ3 boundaries) in company with dislocations emanate from the SAGB (see Fig. 3(c),(d)). However,
from the EBIC-LAADF comparison of Fig. 3(b) it is clear that only the SAGBs are recombination active. By
detailed TEM analysis the perfect boundary dislocations could be identified to be Lomer dislocations. This TEM
analyses is not the scope of this contribution and will published elsewhere. By counting the Lomer dislocations and
partial dislocations at each of the positions it was found that the density of Lomer dislocations is higher at the high
recombination active small angle grain boundaries showing strong EBIC contrast. In Table 1 the EBIC contrast
values for each position evaluated from the grey values of the EBIC image in Fig. 3(a) and the density of the Lomer
dislocations are listed. The contrast values are average values along the sample size (i.e. approximately at the length
of the lines in Fig. 3(a) denoting the positions 1 to 4), and the Lomer dislocation density is the number of Lomer
dislocations along the whole small angle grain boundary length, being investigated.

Table 1. EBIC contrast vs. Lomer dislocation density

<table>
<thead>
<tr>
<th>Position No.</th>
<th>EBIC contrast (%)</th>
<th>Lomer dislocation density (μm⁻¹)</th>
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<tbody>
<tr>
<td>1</td>
<td>92 %</td>
<td>100</td>
</tr>
<tr>
<td>2</td>
<td>78 %</td>
<td>40</td>
</tr>
<tr>
<td>3</td>
<td>68 %</td>
<td>30</td>
</tr>
<tr>
<td>4</td>
<td>38 %</td>
<td>7</td>
</tr>
</tbody>
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5. Discussion

The data of Table 1 suggests a clear correlation between the density of Lomer dislocations and the EBIC contrast,
i.e. the recombination activity. Though this correlation is evident for our sample it still must be proven by
investigating more samples, which is on its way. First results seem to confirm the results shown here. The clear
correlation between Lomer dislocation density and EBIC contrast at the SAGBs is a very strong hint that (possibly
also pure, undecorated, but at least mostly) Lomer dislocations are detrimental to the performance of mc-Si solar
cells. Since Lomer dislocations are immobile, we expect that they are particularly prone for collecting impurities
like iron. During our investigation we could not detect any iron in the Lomer dislocation yet. This is due to the fact
that the volume we are able to investigate by transmission electron microscopy methods is very small: The TEM
lamellas are only about 50 to 100 nm thick and a Lomer dislocation has a typical diameter of about 5 nm. Following
the theoretical predictions of Donolato and Kveder et al. [26,27], saying that a density of impurity atoms (iron?) of
about 10 μm⁻¹ (which is one atom per 100 nm) is enough for strong recombination activity, we expect statistically
only one or two iron atoms in the Lomer dislocation regarding the examined volume in our studies. Hence, with the
methods used in this contribution it is not possible to detect the iron or other impurity atoms having a similar
concentration in the Lomer dislocations.

6. Summary and outlook

Multicrystalline Si solar cells suffer from inherent dark current losses at grain boundaries. The dark current losses
could be identified to be located at small angle grain boundaries. Locally the efficiency losses at these SAGB cluster
accounts up to approximately 5 % absolute. Furthermore, at the small angle grain boundaries we found a clear
correlation between the local density of Lomer dislocations and the recombination activity measured by the EBIC
contrast. Other dislocation types found at the same small angle grain boundary do not show significant
recombination activity in our investigations. Iron could not be detected yet. By investigating more samples recently
it was confirmed that only the density of Lomer dislocations plays a significant role regarding the recombination activity, which will published elsewhere in greater detail in the near future.

Acknowledgements

The authors acknowledge the help of P. Werner and N. Zakharov (both MPI Halle) at the STEM investigations. This work was partly financed by the BMWi Projects No. 0325270C (SolarWins) and 0325763D (SolarLIFE).

References


